What is claimed is:

- 1. A device comprising an isotopically enriched piezoelectric material.
- 2. The device of claim 1 wherein said isotopically enriched piezoelectric material comprises a single crystal structure.
- 3. The device of claim 1 wherein said isotopically enriched piezoelectric material comprises isotopically enriched silicon dioxide.
- 4. The device of claim 2 wherein said isotopically enriched piezoelectric material comprises isotopically enriched silicon dioxide.
- 5. The device of claim 1 wherein said isotopically enriched piezoelectric material comprises isotopically enriched silicon dioxide having a higher proportion of the Si28 isotope than is present in naturally occurring silicon dioxide.
- 6. The device of claim 1 wherein said isotopically enriched piezoelectric material comprises isotopically enriched silicon dioxide wherein at least 94% of the silicon component of said silicon dioxide is Si28.
- 7. The device of claim 1 wherein said isotopically enriched piezoelectric material comprises isotopically enriched silicon dioxide wherein at least 99% of the silicon component of said silicon dioxide is Si28.

- 8. The device of claim 7 wherein said silicon dioxide has a higher proportion of the O16 isotope than is present in naturally occurring silicon dioxide.
- 9. The device of claim 1 wherein said isotopically enriched piezoelectric material comprises isotopically enriched silicon dioxide having a higher proportion of the Si29 isotope than is present in naturally occurring silicon dioxide.
- 10. The device of claim 1 wherein said isotopically enriched piezoelectric material comprises isotopically enriched silicon dioxide having a higher proportion of the Si30 isotope than is present in naturally occurring silicon dioxide.
- 11. The device of claim 1 wherein said isotopically enriched piezoelectric material comprises isotopically enriched silicon dioxide having a higher proportion of the 016 isotope than is present in naturally occurring silicon dioxide.
- 12. The device of claim 1 wherein said isotopically enriched piezoelectric material comprises isotopically enriched zinc oxide.
- 13. The device of claim 1 wherein said isotopically enriched piezoelectric material comprises isotopically enriched titanium dioxide.
- 14. The device of claim 1 wherein said isotopically enriched piezoelectric material comprises isotopically enriched lithium niobate.

- 15. The device of claim 1 wherein said isotopically enriched piezoelectric material comprises isotopically enriched lithium tantalate.
- 16. The device of claim 1 wherein said isotopically enriched piezoelectric material comprises isotopically enriched langasite.
- 17. The device of claim 1 wherein said isotopically enriched piezoelectric material comprises isotopically enriched languatate.
- 18. The device of claim 1 wherein said isotopically enriched piezoelectric material comprises isotopically enriched lead-zirconate-titanate.
- 19. The device of claim 1 wherein said device comprises a clock.
- 20. The device of claim 1 wherein said device comprises an oscillator.
- 21. The device of claim 1 wherein said device comprises an acoustic wave filter.
- 22. The device of claim 1 wherein said device comprises a resonator.
- 23. The device of claim 1 wherein said device comprises a transducer for an ultrasonic surgical instrument.
- 24. The device of claim 1 wherein said device comprises a transducer.
- 25. The device of claim 1 wherein said device comprises a speaker.

- 26. The device of claim 1 wherein said device comprises an ultrasonic speaker.
- 27. The device of claim 1 wherein said device comprises a buzzer.
- 28. The device of claim 1 wherein said device comprises a radar system.
- 29. The device of claim 28 further comprising a low phase noise reference oscillator having a resonator comprising said isotopically enriched piezoelectric material.
- 30. The device of claim 1 comprising a transducer for a non-linear response ultrasonic beam speaker system.
- 31. The device of claim 1 comprising a transducer for an ultrasonic cleaning system.
- 32. A method for producing a single crystal of an isotopically enriched piezoelectric material comprising the steps of:

obtaining said isotopically enriched material in powder form;

converting said isotopically enriched material powder into dendrite crystals by means of a first hydrothermal process; and

producing a single crystal from said dendrite crystals by means of a second hydrothermal process.